ulations remain constant at 0.264 for the smaller basis and at 0.280 for the larger basis. **A** detailed analysis of individual elements of the Mulliken overlap population matrix indicates that π -interactions between Ta and Si are insignificant. Si d functions primarily affect *n* Ta-Si bonding. Most of the non-Ta contributions in 1's LUMO and **2's HOASO** belong to C1 p functions that interact in a π -antibonding sense with Ta's d_{xy} functions.

An important portion of the present analysis concerns Mulliken charges, which can provide a rough summary of the electronic distribution. In all calculations, the silyl group, the phosphine, and the Cp ring have charges that are close to zero. Only the chlorine ligands are unambiguously anionic, with charges of about -0.4 for 1 and **2.** Increasing the d electron count will reduce Coulomb attractions between Ta and the Cl's.

Upon changing from d^0 to d^1 , a combination of electrostatic repulsions and Ta-C1 antibonding character in **2's HOASO** causes the elongation of the average Ta-C1 separation from 2.343 **A** in **A** to 2.405 **A** in B. **As** the Ta is now less crowded in the latter structure, it is possible for Si to approach Ta more closely. (For the same reasons, the observed Ta-Cp(centroid) distance is 0.03 **A** less in B). The expense of these calculations prevents a full optimization of the Ta-Si distance as a function of Ta-Cl distance or other geometric parameters. It is nonetheless possible to state how occupation of the Ta d_{xy} -like MO affects the Ta-ligand separations. Antibonding Ta-Cl character causes the Ta-Cl separation to increase, allowing the Ta-Si distance to decrease. Mulliken charges on the ligands also disclose the electrostatic origin of **2's** longer Ta-Cl separation and the consequent decrease in the Ta-Si distance.

Registry No. $(\eta^5$ -Cp)TaCl₃(SiH₃), 113748-18-8; $(\eta$ -Cp)- $TaCl₂(PH₃)(SiH₃), 113748-19-9.$

Dlmethylsllylene: Spectroscopy, Reactivity, and Complexatlon In Fluid Solutions'

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Received November 30, 1987

Summary: Upon 266-nm laser flash photolysis, cyclohexane solutions of dodecamethylcyclohexasilane give rise to a transient species (λ_{max} = 465 nm) that is best assigned as dimethylsilylene. This species exhibits unusually high reactivity toward alcohols and reagents con-

ABSORBANCE CHANGE 0.05 310 nm 0.04 P 0.03 0.02 0.01 OC **300 350 400 450 500 550 WAVELENGTH, NM** Figure 1. Transient absorption spectra following 266-nm laser
flash photolysis of dodecamethylcyclohexasilane solution in cy-

465 nm

clohexane: A, in the absence of THF and at $0.1 \mu s$ following the laser flash, and B, in the presence of 0.8 mM THF and at $1.3 \mu s$ following laser flash. Note that the two spectra were taken under different conditions of laser intensity and ground-state absorbance. Insets: kinetic traces showing (a) the enhanced decay of the 465-nm species in the presence of 0.8 mM THF and (b) the concomitant formation of transient absorption at 310 nm.

taining Si-H, C=C, and C=C bonds (with rate constants in the limit of diffusion control) and readily forms complexes with lone-pair containing molecules (ethers, triethylamine, and acetonitrile), the latter showing considerably reduced reactivity relative to the "free" silylene.

Currently, considerable interest is being shown in divalent silicon intermediates, i.e., second-row analogues of $carbenes.³$ In particular, dimethylsilylene (1) has been at the center of controversy for a number of years. $4-6$ This species is claimed to be formed as a bright yellow product $(\lambda_{\text{max}} = 430 - 470 \text{ nm})$ of photolysis of various precursors (e.g., **dodecamethylcyclohexasilane, 2)** in low-temperature inert gas or hydrocarbon matrices4 **as** well **as** in the course of flash pyrolysis of suitable substrates followed by isolation in low-temperature N_2 or Ar matrices.⁵ In contrast, laser flash photolysis (308-nm) experiments with **2** in fluid hydrocarbon solutions at room temperature have been negative regarding the observation of the 450-nm species;

⁽¹⁾ This work was supported in part by the Office of Basic Energy Sciences, Department of Energy. This is Document No. NDRL-3032 from the Notre Dame Radiation Laboratory.

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Table 1. Reactivity of Uncomplexed and Complexed Dimethylsilylene in Cyclohexane at 296 K

complexing agent	λ_{max} nm	τ, μS	reagent	$10^{9}h$. ^a M^{-1} s ⁻¹
none	465	0.4	oxygen	$2.2\,$
			ethanol	3.9
			2-butanol	10.1
			2-methyl-2-propanol	10.2
			$tri-n$ -propylsilane	2.9
			1-hexene	7.3
			trimethylvinylsilane	5.9
			trimethylacetenylsilane	8.0
			THF	12.7
THF	310	12.5	ethanol	0.19
			tri- <i>n</i> -propylsilane	~ 0.001
			2-methyl-2-propanol	0.044
			1-hexene	0.0024
			trimethylvinylsilane	0.0026
diethyl ether	305	4.0	ethanol	0.98
triethylamine	$~1$ 270	29	ethanol	0.033
acetonitrile	340	2.3	ethanol	0.11

^a Maximum deviation, $\pm 20\%$ (from 2σ of least-squares linear fits).

instead, a transient characterized by λ_{max} at 350 nm and lifetime (τ) of 8 μ s in 3-methylpentane and cyclopentane has been noted.⁶ We have carried out a 266- and 248-nm laser flash photolysis study of **2** in cyclohexane solution

at 296 K; this clearly shows the photogeneration of a
\n
$$
[(CH_3)_2Si]_6 \rightarrow [(CH_3)_2Si]_5 + (CH_3)_2Si: \text{(1)}
$$
\n
$$
2
$$

transient intermediate with absorption spectrum, kinetic behavior, and reactivity that fit very well the description of dimethylsilylene, 1. Interestingly, this species reacts with suitable organic Lewis bases (e.g., ethers and tertiary amines) forming complexes characterized by blue-shifted absorption spectra and significantly subdued reactivity (relative to "naked" dimethylsilylene).

The 266-nm laser pulse excitation' of deoxygenated cyclohexane solutions of **2** leads to the formation of a transient species characterized by a broad absorption spectrum $(\lambda_{\text{max}} = 465 \text{ nm})$, see Figure 1A) and a typical lifetime8 of 400 ns. A similar transient is also produced upon 248-nm laser flash photolysis. Oxygen sensitive, the decay of the 465-nm species is enhanced in the presence of millimolar concentrations of reagents that are recognized to react with silylene intermediates (namely, alcohols and compounds containing Si-H and C-C multiple bonds). The plots of pseudo-first-order rate constants for decay against reagent concentrations were linear in each case. The bimolecular rate constants *(k)* obtained from the slopes of the plots are given in Table I. Steady-state

(8) Shorter lifetimes (first order) as well as longer ones (mixed with second order) were also noted in some of the measurements. We believe that the lack of reproducibility of τ is due to adventitious impurities.

competition experiments in which 2 was photolyzed⁹ in the presence of varying concentrations of ethanol and tri-npropylsilane (in cyclohexane) and the corresponding insertion products were analyzed⁹ gave a value of 2.1 for the ratio of the reactivity of the two reagents. This value is close to the observed ratio of 1.4 for the absolute rate constants for the two reagents (Table I).

The 465-nm species derived from **2** under 266-nm laser flash photolysis is readily quenched by reagents containing lone pairs of electrons, namely, tetrahydrofuran (THF), diethyl ether, triethylamine, and acetonitrile. In each case, as a result of the interaction, the long-wavelength absorption spectrum is replaced by one that is considerably blue-shifted. This is illustrated by the transient absorption spectrum (Figure 1B, $\lambda_{\text{max}} = 310 \text{ nm}$) in the presence of THF and by concurrent decay/formation kinetics of absorption (see insets of Figure 1). Upon complexation, 1 becomes longer lived than when it is "free". At the same time, its reactivity becomes considerably reduced **as** shown by the bimolecular rate constants *(k)* measured for the complexes and typical reagents (Table I). Specifically, the relative decrease in *k* upon complexation with THF is higher by several orders of magnitude for tri-n-propylsilane than for ethanol; this is supported by the results of competition experiments under steady-state irradiation in the presence of THF.

On the basis of our results, the following observations can be made. First, the 465-nm phototransient in fluid solutions, best described as "free" dimethylsilylene, is spectrally similar to the 430-470 nm photoproduct ob $served$ by Michl and co-workers 4 in low-temperature matrices. Theoretical calculations^{10,11} predict singlet-singlet absorption maxima in a similar spectral region. Second, "free" dimethylsilylene is unusually reactive. The bimolecular rate constants (Table I) are in the limit of diffusion control and are significantly higher than those obtained by Gaspar and co-workers^{3a} for related systems. On the other hand, the *k* value for tri-n-propylsilane (Table I) agrees well with that measured by Baggott et a1.12 for trimethylsilane in the gas phase at 295 K. Interestingly, the alcohols behave as nucleophiles interacting with the vacant p orbital of the silylene, **as** evident from the increase in *k* on going from ethanol to 2-butanol or tert-butyl alcohol. Third, lone-pair donors form well-defined complexes with dimethylsilylene. The reduced reactivity of these complexes underlines the importance of the vacant p orbital of "free" silylene in rendering insertion reactions facile.

Registry No. 1,6376-86-9; l-THF, 113686-61-6; 1-diethyl ether, 113686-62-7; 1-triethylamine, 113686-63-8; 1-acetonitrile, 113686-64-9; 2, 4098-30-0; THF, 109-99-9; $[{\rm (CH_3)_2Si}]_5$, 13452-92-1; oxygen, 7782-44-7; ethanol, 64-17-5; 2-butanol, 78-92-2; 2 methyl-2-propanol, 75-65-0; tri-n-propylsilane, 998-29-8; 1-hexene, 592-41-6; trimethylvinylsilane, 754-05-2; trimethylacetylenesilane, 1066-54-2.

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